



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Tatsuya SHIMODA et al.

Application No.: 09/403,543

Filed: October 25, 1999

For: THREE DIMENSIONAL DEVICE

Group Art Unit: 2823

Examiner: S. S. Foong

Docket No.: 104270

19/11
Shimoda
9/3/02

AMENDMENT UNDER 37 C.F.R. §1.111

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

In reply to the Office Action dated April 24, 2002, the period for reply being extended by the attached Petition for Extension of Time, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 1, 2, 3, 12, 17, 21 and 25 as follows:

1. (Four Times Amended) A method of forming a three-dimensional device, the device including at least a first thin film device layer and a second thin film device layer, each deposited in a thickness direction, the method comprising:
- forming the first thin film device layer on a first substrate;
 - forming the second thin film device layer on a second substrate with a separable layer therebetween; and

Amended
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